

Nova Universal Eco-2 Developer

Developer for Thermal and CTcP-UV positive plates

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Properties

- **DURABILITY:** Its specific formulation permits high productivity in square meters developed.
- CLEANING: Its dissolution capability reduces the accumulation of emulsion in the filters, rollers and bath tank, keeping them cleaner.
- COMPATIBILITY: Capable to develop the major positive
 Thermal CTP (except closed systems) and CTcP UV plates.

- Non-aggressive to the anodizing layer of the plates.
- With buffered agents to minimize the aggression to the image area.
- It contains corrosion inhibitors.
- Conductivity: 83-87 mS (at 25°C).

How to use *

PLATE	WORKING TEMPERATURE	DEVELOPING TIME
Nova Aventus	23 ± 1℃	25± 5 sec.

DEVELOPER	TOP UP RATES
Replenishment rate	100 - 120 ml/m ²
Anti-ox Standby ON	120 - 140 ml/h
Anti-ox Standby OFF	120 - 140 ml/h

^{*} These values may vary depending on the conditions and type of the processor.

Packaging

20 liters. (Other packaging available under request).



